

Geant4 simulation of the ionisation energy loss fluctuation in the GaAs and Si sensors

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- PAI model in Geant4
- Energy loss fluctuations in GaAs sensors
- e – h pairs distributions
- Energy loss fluctuations in Si sensors
- e – h pairs distributions
- Conclusions

PAI model

$$\frac{d\sigma_i}{d\omega} = \frac{\alpha}{\pi\beta^2} \left\{ \frac{\tilde{\sigma}_\gamma}{|\varepsilon(\omega)|^2} \left[\ln \frac{2mv^2}{\omega|1-\beta^2\varepsilon|} - \frac{\varepsilon_1 - \beta^2|\varepsilon|^2}{\varepsilon_2} \arg(1 - \beta^2\varepsilon^*) \right] + \frac{1}{\omega^2} \int_{I_1}^{\omega} \frac{\tilde{\sigma}_\gamma(\omega')}{|\varepsilon(\omega')|^2} d\omega' \right\}$$

σ_i = cross section of ionising collision
 ω = energy transfer

V. M. Grichine et al, NIM A 453, 2000

$$\varepsilon_1(\omega) = \frac{N\hbar c}{\omega} \tilde{\sigma}_\gamma(\omega)$$

$\varepsilon = \varepsilon_1 + i\varepsilon_2$ - dielectric constant of the medium
 $\tilde{\sigma}_\gamma(\omega)$ the normalised photo absorption cross section

$$\int_{I_1}^{\omega_{max}} \tilde{\sigma}_\gamma(\omega') d\omega' = \frac{2\pi^2 \hbar e^2 Z}{mc}$$

m, e – electron mass, charge

\hbar - Planck constant

$\beta = v/c$ ratio of particle velocity and speed of light

Z – effective atomic number

N – number of atoms in unit volume

α - electromagnetic strength constant

I_1 - the first ionisation potential

GEANT4

□ Parameterization of the photo-absorption cross section

$$\sigma_\gamma(\omega) = \sum_{k=1}^4 a_k^i \omega^{-k}$$

on i energetic intervals from 0.01 eV to 500 eV. They are determined by fits with experimental data.

□ MC generation of

- number of ionisation interactions according to the Poisson distribution

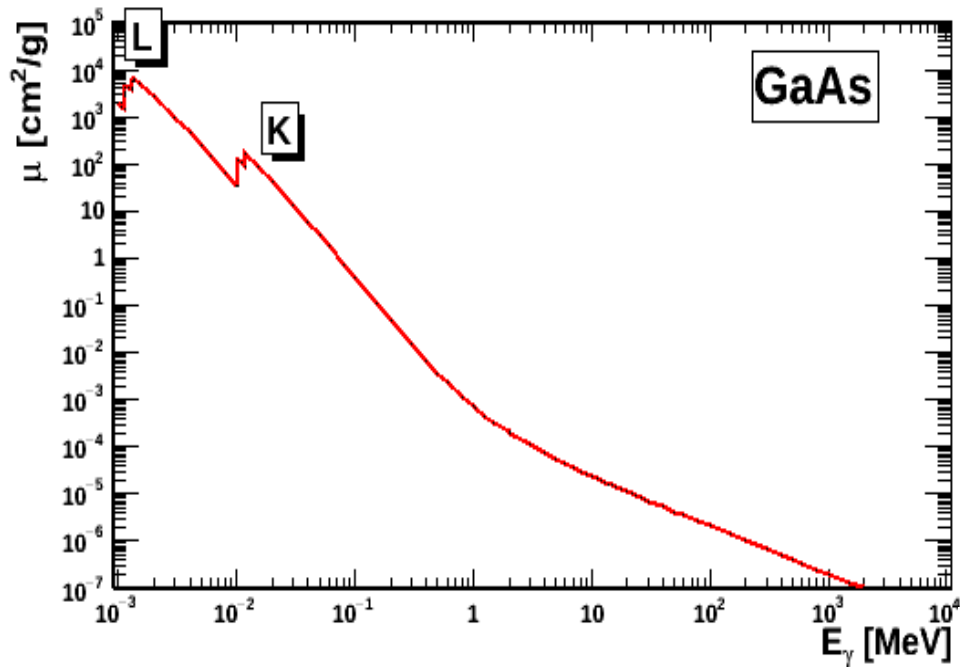
$$P_k^n = \frac{n^k}{k!} e^{-n}$$

$$n \sim \sigma_i(> \omega) = \int_{I_1}^{\omega_{max}} \frac{d\sigma_i(\omega')}{d\omega'} d\omega'$$

- and energy transfer w according to the integral distribution

$$\sigma_i(> \omega) = \int_{\omega}^{\omega_{max}} \frac{d\sigma_i(\omega')}{d\omega'} d\omega'$$

Mass attenuation coefficient in GaAs and Si (NIST data)



Landau model – „free electron”

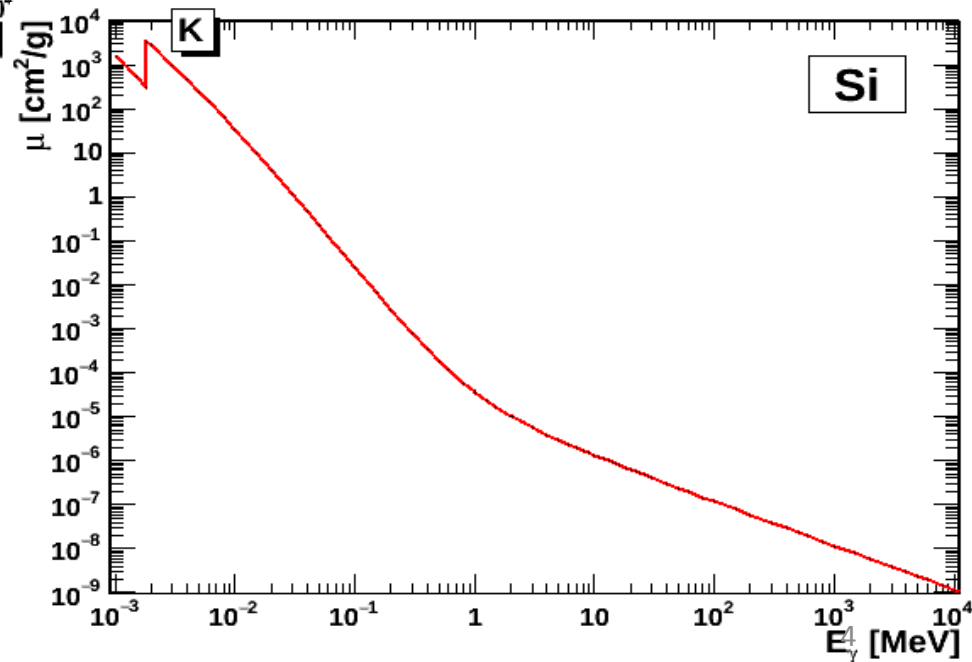
$$P = \left(\frac{2\pi N_A e^4 \rho}{m v^2} \right) (Z/A) (1/\omega^2)$$

m , e – electron mass and charge,
 A - relative atomic mass of absorber
 ρ density of the absorber
 N_A – Avogadro number
 ω - loses energy

$$\mu/\rho = \sigma_\gamma/uA$$

u atomic mass

A relative atomic mass of the target element



PAI Physics List

ClassName: DetectorConstruction

```
G4Region* aPad = new G4Region("aPad");  
aPad->AddRootLogicalVolume(pad3_log);
```

PAI applies to $e^{\pm}, \gamma, p, \pi^{\pm}, \mu^{\pm}$

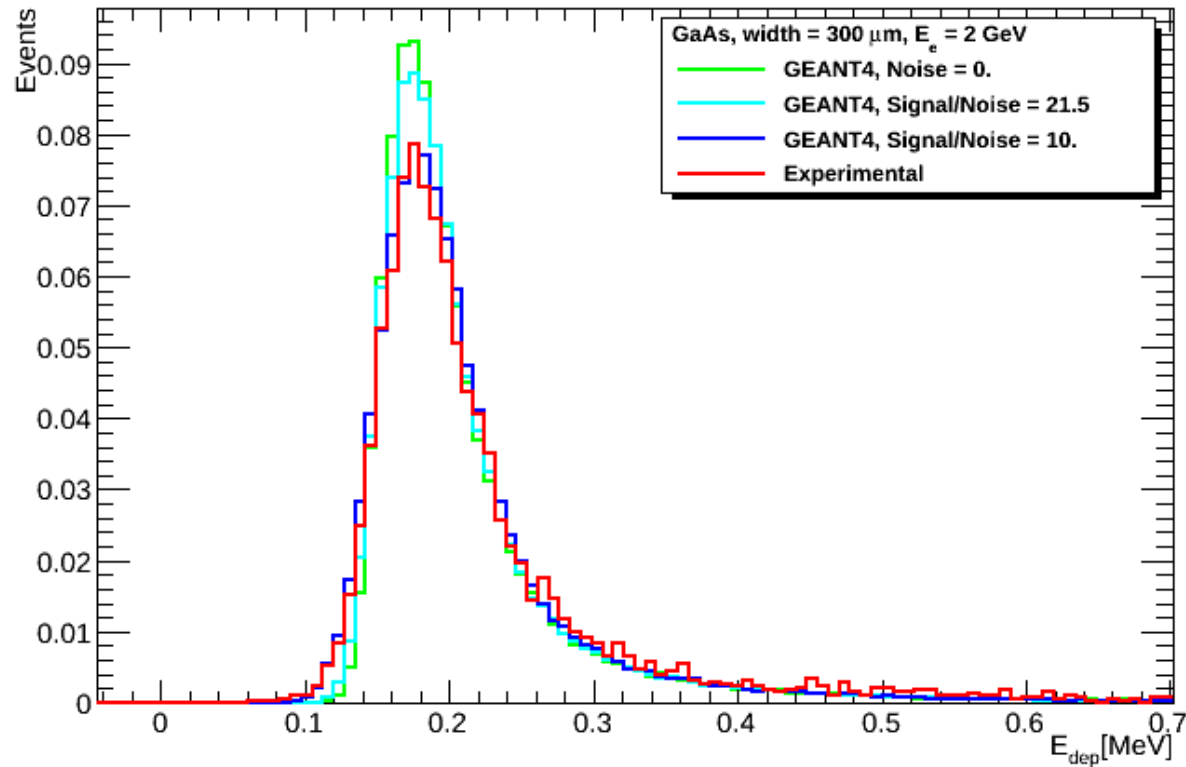
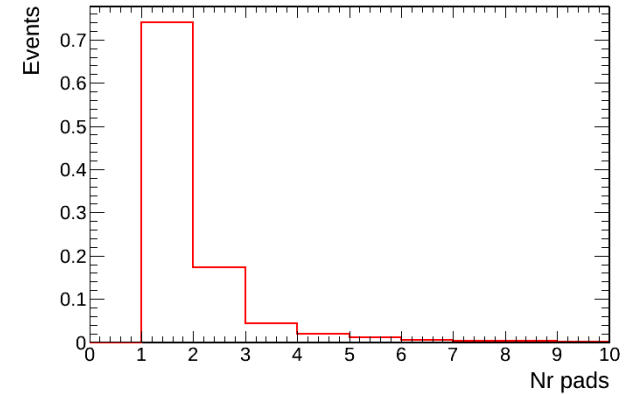
```
ClassName: PhysicsList  
// Description: EM physics with a possibility to add PAI model  
// Author: V.Ivanchenko  
.....  
#include "G4PAIModel.hh"  
#include "G4PAIPhotonModel.hh"  
.....  
-----  
//Get the Region  
G4Region* aPad = G4RegionStore::GetInstance()->GetRegion("aPad");  
//Define cuts object for the aPad region and set values  
G4ProductionCuts* cuts = new G4ProductionCuts;  
cuts->SetProductionCut(0.01*mm); //same for e+, e- and gamma  
.....  
-----  
void PhysicsList::NewPAIModel(const G4ParticleDefinition* part,  
                             const G4String& modname,  
                             const G4String& procname)  
{  
  G4String partname = part->GetParticleName();  
  if(modname == "pai") {  
    G4PAIModel* pai = new G4PAIModel(part, "PAIModel");  
    fConfig->SetExtraEmModel(partname, procname, pai, "aPad", 0.0, 100.*TeV, pai);  
  } else if(modname == "pai_photon") {  
    G4PAIPhotonModel* pai = new G4PAIPhotonModel(part, "PAIPhotModel");  
    fConfig->SetExtraEmModel(partname, procname, pai, "aPad", 0.0, 100.*TeV, pai);  
  }  
}
```

Energy loss fluctuation in GaAs

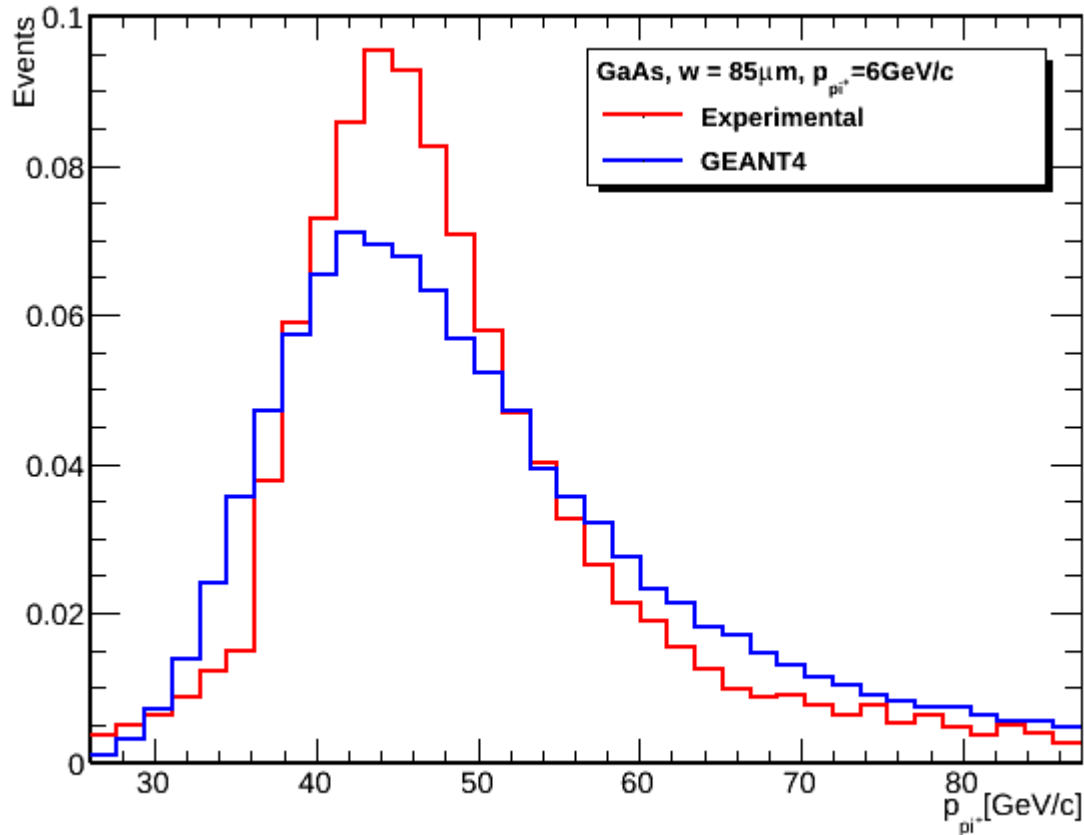
GaAs 300 μm
 $E_{e^-} = 2 \text{ GeV}$

$$\mathbf{S} = \sum_{i=1}^{N_{cluster}} \mathbf{S}_i$$

Testbeam 2011 experimental data

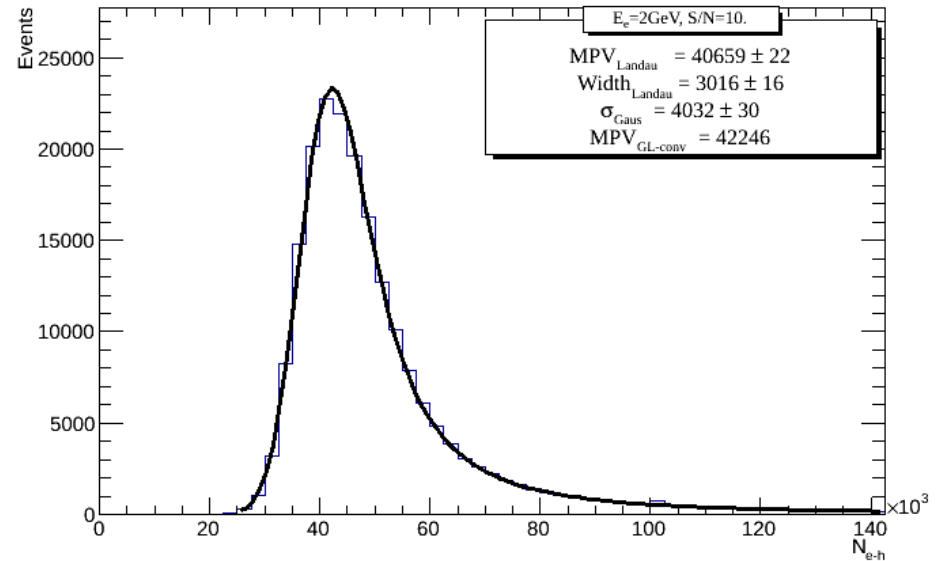
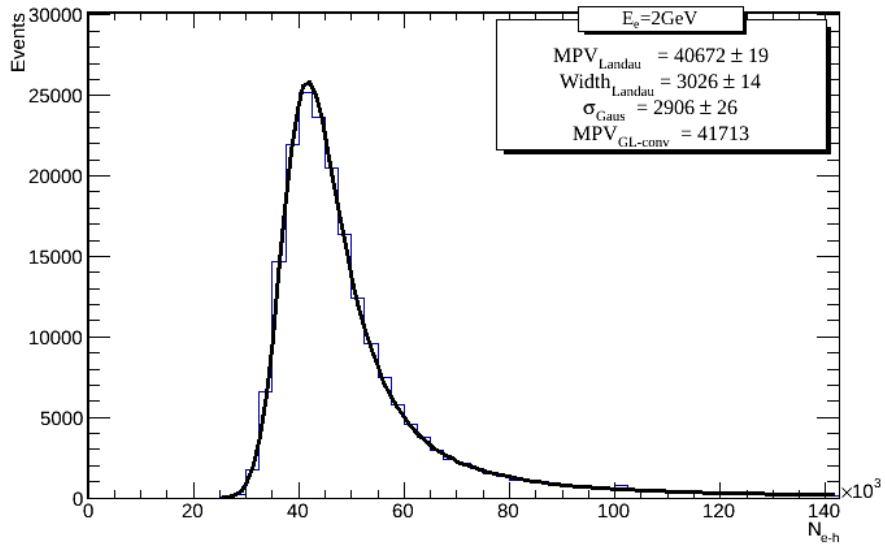


Energy loss fluctuation in Ga As



- Experimental data from J. Apostolakis, ..., V.M. Grichine NIM A45(2000)597
- Original experimental data without calibration in: R. Bertin, S. D'Auria, C. Del Para et al., Nucl. Instr. and Meth. A 294 (1990) 211

Number of e-h pairs created in GaAs sensor

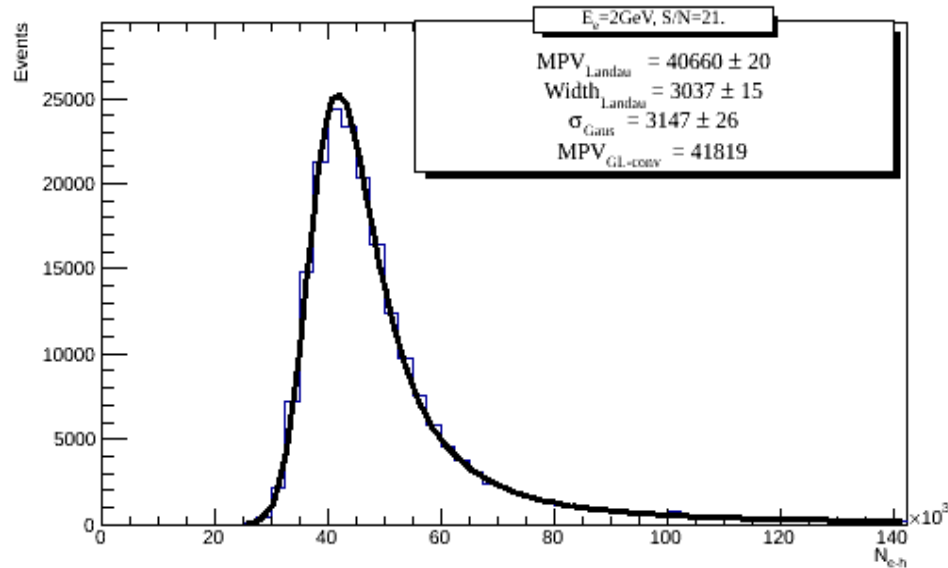


Thickness = $300 \mu\text{m}$

$E_{e^-} = 2 \text{ GeV}$

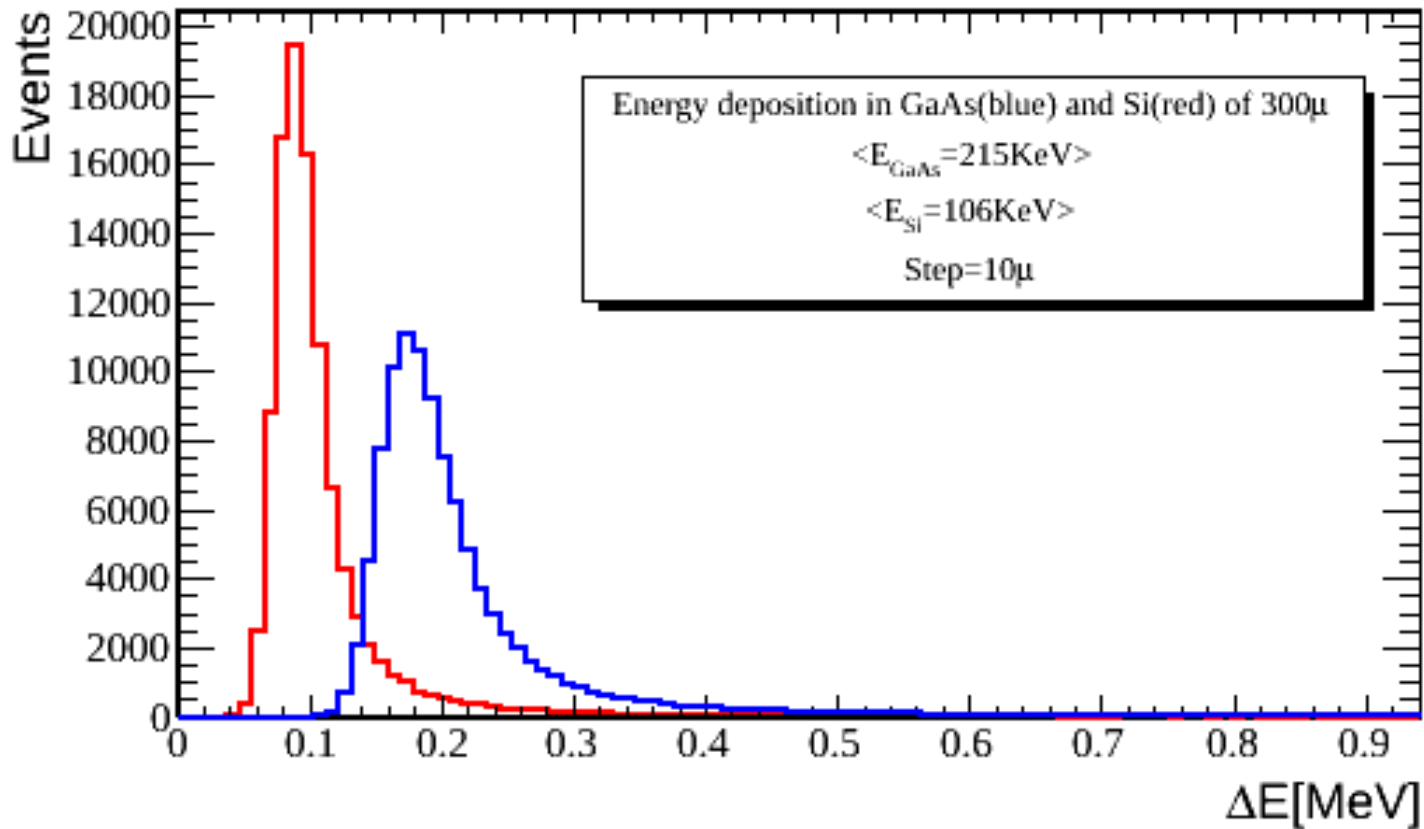
$$n = \frac{E_{dep}}{E_i}$$

$E_i = 4.2 \text{ eV}$

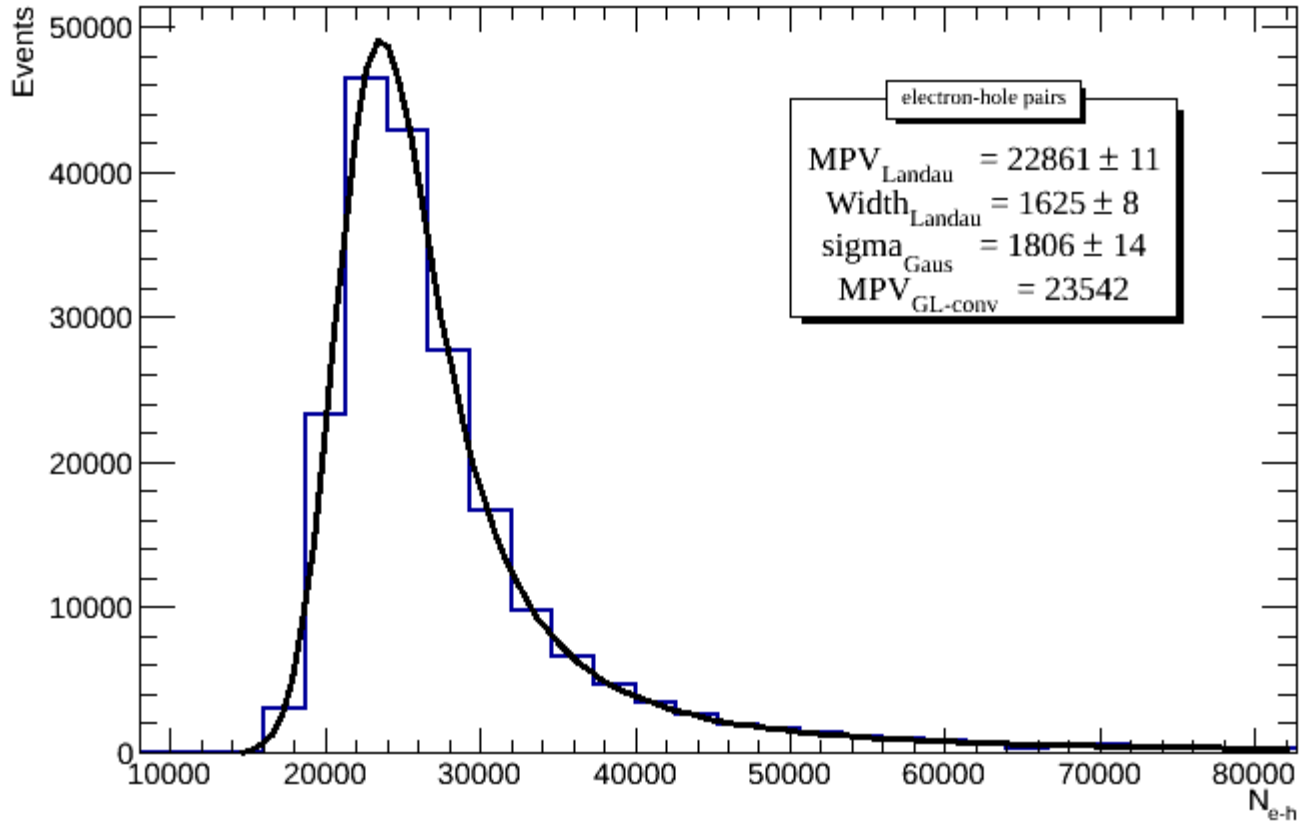


Energy deposited

material	$E_i(\text{eV})$	μ_e	μ_h	ρ	$\langle Z \rangle$
Si	3,6	1350	450	2,33	14
Ga As	4,2	8000	400	5,32	31,5



Number of e-h pairs in Si sensor



Thickness = 300 μm

$E_{e^-} = 2 \text{ GeV}$

$$n = \frac{E_{dep}}{E_i}$$

$E_i = 3,6 \text{ eV}$

Similar value
obtained for π at
minimum ionisation

MPV_{GL-conv} = 23512

Conclusions

- Simulations of the GaAs & Si sensors were performed using PAI model
- Very good agreement between simulations and experimental data, even for very thin sensors
- PAI could be used successfully for thin sensitive materials in electromagnetic and hadronic calorimeters.

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